MD Simulations of Microstructure Evolution During High-Velocity Sliding Between Crystalline Materials

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Following are corrections to the original article:

On p. 300, in the caption to Figure 2, 0.219 should be replaced by 1.461.

On p. 301, line 12, 0.01 should be replaced by 0.033.

On p. 301, line 33, 0.15 should be replaced by 0.074.

On p. 301, in line 2 of Results and Discussion, 0.219 should be replaced by 1.461.

On p. 302, in the caption to Figure 4, 0.219 should be replaced by 1.461.

On p. 302, line 7, s^2 should be replaced by σ^2 .

These corrections do not affect the results and conclusions given in the paper.

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